CAS/STN FILE 'REGISTRY' ENTERED AT 09:53:00 ON 20 MAY 2002 L1 17688 S "O SI"/ELF

FILE 'HCAPLUS' ENTERED AT 09:53:01 ON 20 MAY 2002 356869 S L1

FILE 'REGISTRY' ENTERED AT 09:53:11 ON 20 MAY 2002 1 S "OSI. UNSPECIFIED"/ELF

FILE 'HCAPLUS' ENTERED AT 09:53:14 ON 20 MAY 2002

L4 1 S L3

356869 S L2 OR L4

FILE 'REGISTRY' ENTERED AT 09:53:59 ON 20 MAY 2002 L6 13 S ("HOSI"/MFOR "HOSI, 2 H"/MFOR "HO SI . H"/MF) OR ("H O SI2"/MF OR "H O SI37"/MF)

FILE 'HCAPLUS' ENTERED AT 09:55:30 ON 20 MAY 2002 L7 104 S L6

FILE 'REGISTRY' ENTERED AT 09:56:54 ON 20 MAY 2002

11181 S ?SILOXAN? AND (POLYMER OR MONOMER OR OLIGOMER OR HOMOPOLYMER OR COPOLYMER)

L9 11181 S SILOXAN? AND (POLYMER OR MONOMER OR OLIGOMER OR HOMOPOLYMER OR COPOLYMER)

L10 554 S POLYSILOXAN?

L11 0 S SILOXANE/CN

0 S SILOXANE/CN L12

0 S POLYSILOXANE/CN L13

L14 24967 S SILOXANE/BI

FILE 'HCAPLUS' ENTERED AT 10:00:43 ON 20 MAY 2002

0 S L7(L)HYDROPHOB#######

L16 6112 S L5(L)(OH OR HYDROX####)

L17 16969 S L5(L)SURFACE

L18 1543 S L5(L)HYDROPHOB######

L19 563 S L16 AND L17

L20 14 S L16 AND L18

L21 248 S L17 AND L18

L22 12 S L7(L)SURFACE

L23 33 S L7(L)(OH OR HYDROX####)

L24 7 S L19 AND L20 AND L21

L25 5 S L22 AND L23

L26 33114 S (L8 OR L9 OR L10) OR L14

L27 12 S (L24 OR L25) L28 3 S L27(L)?SILOXAN?

L29 356919 S L7 OR L5

L30 2558 S L29(L)?SILOXAN?

L31 2 S L27 AND L30

L32 3 S L27 AND (L26 OR ?SILOXAN?)

L33 3 S (L31 OR L32) **SEL RN**

L34

17194-00-2/BI OR 1825-62-3/BI OR 497-19-8/BI OR 584-08-7/BI OR 7782-42-5/BI) L35 4844 S (L7 OR L5) AND HYDROPHOB#######

L36 3362 S L35 AND (SURFACE OR SURFACTANT##### OR

LAYER OR FILM OR HORIZONTAL#### OR "ONTO" OR "INTO")

3 S L33 AND (1310-58-3/BI OR 1310-73-2/BI OR 7631-86-9/BI OR 14807-96-6/BI OR

FILE 'HCAPLUS' ENTERED AT 10:00:43 ON 20 MAY 2002

L37	650 S L36 AND (L26 OR ?SILOXAN?)
L38	334 S L26(L)HYDROPHOB########
L39	1377 S ?SILÓXAN?(8A)HYDROPHOB#########
L40	248 S L37 AND (L38 OR L39)
L41	9236 S ?SILOXAN?(8A)(SIO OR SIO2 OR SILICON OR SILICA)
L42	1930 S L26(L)(SIO OR SIO2 OR SILICON OR SILICA)
L43	156 S L40 AND (L41 OR L42)
L44	63575 S L5(L)SURFACE OR SURFACE(3A)(SIO OR SIO2 OR
	SILICON OR SILICA)
L45	72 S L43 AND L44
L46	The state of the s
	OLIGOMER OR MONOMOER OR HOMOPOLYMER OR COPOLYMED/(2A)2811 OVALIS
L47	4153 S L5(L)HYDROPHOB####### OR HYDROPHOB#######(5A)(SIO OR SIO2 OR
	SILICON OP SILICA)
L48	41 5 L46 AND L47
L49	39 S L48 NOT L34
L50	697562 S "SEMICONDUCTOR DEVICES"+ALL/CT
L51	12 S (L20 OR (L22 OR L23 OR L24 OR L25) OR (L27 OR L28) OR (L31 OR L32 OR L33 OR
	L34) OK (L45 OK L46)) AND L50
L52	1 S L51 AND HYDROPHOB?
L53	6293 S L50 AND (L8 OR L9 OR L10 OR ?SILOXAN?)
L54	157 S L53 AND HYDROPHOB?
L55	49 S L54 AND (L7 OR L5)
L56	48 S L55 NOT (L51 OR L49 OR L34 OR L4)
	S L56 AND (OH OR H O/ELF OR HYDROX#####)
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FILE 'REGISTRY' ENTERED AT 10:33:44 ON 20 MAY 2002

L57 126783 S H O/ELF

FILE 'HCAPLUS' ENTERED AT 10:33:45 ON 20 MAY 2002

- L58 565032 S L57
- L59 20 S L56 AND (OH OR L58 OR HYDROX#####)
- 7727 S (POROUS OR NANOPOR###### OR POROS###### OR PORE)(1A)(SIO OR SIO2 L60 OR (SI OR SILICON)(W)OXIDE OR (SI OR SILICON)(W)DIOXIDE OR SILICA)
- L61 5 S L54 AND L60
- 0 S (POROUS OR NANOPOR###### OR POROS###### OR PORE)(1A)(SI OR L62 SILICON)(W)HYDROXIDE
- 1 S (POROUS OR NANOPOR###### OR POROS###### OR PORE)(1A)SIOH L63